

	Hits	Search Text	DBs
55	8	((capacitor or device) same (((photosensitive or (light near6 sensitiv\$5)) near26 sol\$3gel) or ((titanium or Ti) near28 sol\$3gel) or (Ti\$2Al near24 organic near4 gel) or (titanium near9 alumin\$3 near24 sol\$3gel))) and (((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or (hard near9 mask) or expos\$3 or illuminat\$3 or irradiat\$3)) or pattern\$4) and ((etch\$4 or (ion near4 mill\$4)) same ((top near4 electrode) or (bottom near4 electrode)) same (dielectric or insulator))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
56	8	((capacitor or device or (top near5 electrode) or (bottom near9 electrode)) same (((photosensitive or (light near6 sensitiv\$5)) near26 sol\$3gel) or ((titanium or Ti) near28 sol\$3gel) or (Ti\$2Al near24 organic near4 gel) or (titanium near9 alumin\$3 near24 sol\$3gel))) and (((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or (hard near9 mask) or expos\$3 or illuminat\$3 or irradiat\$3)) or pattern\$4) and ((etch\$4 or (ion near4 mill\$4)) same ((top near4 electrode) or (bottom near4 electrode)) same (dielectric or insulator))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
57	115	((capacitor or device or (top near9 electrode) or (bottom near5 electrode)) same (((photosensitive or (light near6 sensitiv\$5)) near26 sol\$3gel) or ((titanium or Ti) near28 sol\$3gel) or (Ti\$2Al near24 organic near4 gel) or (titanium near9 alumin\$3 near24 sol\$3gel))) and (((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or (hard near9 mask) or expos\$3 or illuminat\$3 or irradiat\$3)) or pattern\$4)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB